

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L9	0	"10036955".ap.	US-PGPUB; USPAT	OR	ON	2005/04/05 09:21
L10	4	"036955".ap.	US-PGPUB; USPAT	OR	ON	2005/04/05 09:21
L12	3	((("20020190375") or ("20020115226") or ("20020079525")).PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/04/05 15:13
L13	1857	"metal silicide" and "diffusion layer"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/05 15:14
L14	1018	"metal silicide" and "diffusion layer"	USPAT	OR	ON	2005/04/05 15:14
L15	355	"metal silicide" and "diffusion layer" and insulation	USPAT	OR	ON	2005/04/05 15:16
L16	483	"metal silicide" with "diffusion layer"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/05 15:16
S1	1504	(257/774).CCLS.	USPAT; USOCR	OR	OFF	2005/03/31 08:56
S2	2181	(257/774).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/31 14:09
S3	3182	(257/758).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/29 15:20
S7	2688	(257/758).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/03/29 15:23
S8	1844	(257/758).CCLS.	USPAT	OR	OFF	2005/03/29 15:23
S9	5	((("6844241") or ("6699787") or ("6664129") or ("6841849") or ("20020017710")).PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/04/05 09:41
S10	705	substrate and "diffusion layer" and insulation and stack\$4	USPAT	OR	OFF	2005/03/31 14:11

S11	1106	substrate and "diffusion layer" and insulation and stack\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/04 09:27
S12	1950	(257/774).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/04/01 10:06
S14	4	("5335138" "6171910" "6339008").PN. OR ("6602721").URPN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/04/04 09:14
S15	4	("5073516" "5512785" "6140705" "6156664").PN. OR ("6531778").URPN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/04/04 09:23
S16	3	("10223833").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/04 09:23
S17	2747	substrate and diffusion adj (film or layer or pattern) and (insulat\$3 or isolat\$3) adj (film or layer or pattern) and stack\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/04 09:38
S18	781	substrate and diffusion adj (film or layer or pattern) and (insulat\$3 or isolat\$3) adj (film or layer or pattern) and (through adj (hole or plug))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/04 14:57
S19	1327	(257/751).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/04 10:51
S20	83	"diffusion layer pattern"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/04 13:53
S21	4	("5335138" "6171910" "6339008").PN. OR ("6602721").URPN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/04/04 14:50
S22	3973	diffusion adj (film or layer or pattern or region) and (insulat\$3 or isolat\$3) adj (film or layer or pattern or region) and (through adj (hole or plug or contact))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/04 15:03

S23	1496	diffusion adj (film or layer or pattern or region) and (insulat\$3 or isolat\$3) adj (film or layer or pattern or region) and (through adj (hole or plug or contact)) and silicide	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/04 15:03
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